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Enhancement of electron-hole superfluidity in double few-layer graphene

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We propose two coupled electron-hole sheets of few-layer graphene as a new nanostructure to observe superfluidity at enhanced densities and enhanced transition temperatures. For ABC stacked few-layer graphene we show that the strongly correlated electron-hole pairing regime is readily accessible experimentally using current technologies. We find for double trilayer and quadlayer graphene sheets spatially separated by a nano-thick hexagonal boron-nitride insulating barrier, that the transition temperature for electron-hole superfluidity can approach temperatures of 40 K.

he prediction of electron-hole superfluidity in spatially separated electron and hole layers has captured the attention of the scientific community¹. The recent intense interest results from suggestions that some double-layer electron-hole systems offer the possibility of observing a coherent superfluid state up to temperatures approaching room temperature². Despite long standing theoretical predictions¹⁻³ and considerable experimental efforts⁴⁻⁶ such electron-hole superfluidity in double layered systems has not yet been observed in zero magnetic field.

Soon after the discovery of graphene, a two-dimensional lattice of carbon atoms, efforts were made to look for superfluidity in graphene-based double monolayer devices^{10,11}. Although the early theoretical work on graphene double monolayers predicted room-temperature superfluidity², recent Coulomb drag experiments have found no evidence of superfluidity12. It is, in fact the linear energy dispersion of monolayer graphene that makes it difficult to access the most promising phase space region for superfluidity which is the region where the average strength of the Coulomb interactions between carriers is much larger than their average kinetic energy. The reason is the following. The most favourable conditions for the electron-hole pairing are achieved at small interlayer separations d, when $k_F d \ll 1$. In this optimal limit the behavior of the system is determined by the dimensionless interaction parameter $r_s = \langle V \rangle / E_F$ (ref. 13). E_F is the Fermi energy and $\langle V \rangle = e^2 / (\kappa \langle r_0 \rangle)$ is the average Coulomb energy for the mean inter-particle spacing in a sheet, $\langle r_0 \rangle = 1/\sqrt{n\pi}$, n is the charge carrier density in the sheet and κ is the dielectric constant of the barrier. For monolayer graphene, $E_F = \hbar v_F k_F$, where the graphene Fermi velocity $v_F \simeq 10^6 \text{ ms}^{-1}$, the Fermi momentum $k_F = \sqrt{4\pi n/g_s g_v}$, and the spin (valley) degeneracy for graphene is $g_s = 2$ ($g_v = 2$). This gives for monolayer graphene a value of $r_s = e^2/[\kappa\hbar v_F]$ that is constant, independent of the density¹⁴. The dielectric constant for a hexagonal boron-nitride (h-BN) insulating barrier is $\kappa \approx 3$ (ref. 15), giving r_s a very small (and fixed) value of only $r_s = 0.7$. Calculations for double monolayer graphene unfortunately indicate that unless the parameter r_s exceeds $r_s \ge 2.3$, screening of the electron-hole attractive interaction suppresses superfluidity at all practicable non-zero temperatures¹³. This makes it very difficult to experimentally realize electron-hole superfluidity in double monolayer graphene¹².

Recently it has been suggested that a pair of bilayer graphene sheets is a promising system for observing high temperature superfluidity¹⁶. In contrast with monolayer graphene, bilayer graphene has a quadratic dispersion at low energies so its parameter r_s has an inverse density dependence $r_s \sim 1/\sqrt{n}$ that is familiar from metals and semiconductors. This density dependence makes it possible to experimentally access the strongly interacting regime at large r_s simply by reducing n. Calculations for double bilayer graphene indicate that, the interaction parameter r_s must exceed a value similar to that for double monolayer graphene, $r_s \gtrsim 2.3$, in order for the superfluid to condense at non-zero temperatures¹⁶. It should be noted that outside the optimal region for superfluidity $k_F d \ll 1$, superfluid state properties start to be sensitive also to the barrier thickness d. With increasing

Q

 $d > 1/k_F$, there is (i) an increase in the minimum value of r_s at which finite-temperature superfluidity occurs, and (ii) a decrease in the maximum gap $\Delta_{\rm max}$.

In this paper we investigate the possibility of using graphene systems consisting of double few-layers in excess of two (that is, the bilayer case) in order to access regions of phase space that are even more strongly interacting, with very large values of r_s . We shall see that such systems offer further potential advantages arising from divergences in the density of states caused by van Hove singularities.

Based on the two-band Dirac-Weyl equation describing the lowest energy band in ABC stacked *N*-layer graphene, the energy dispersion of the conduction band is given by refs. 17, 18,

$$E^{(N)}(k) = \{ (\hbar v_F)^N / t^{N-1} \} k^N, \tag{1}$$

where $t \approx 400$ meV is the interlayer hopping term in few-layer graphene. Figure 1(a) shows $E^{(N)}(k)$ for N=1 to 4. We then obtain in N-layer graphene,

$$r_{s} = \left\{ \frac{e^{2}t^{N-1}}{\kappa(\hbar \nu_{F})^{N} \sqrt{\pi^{N-1}}} \right\} \frac{1}{n^{(N-1)/2}}.$$
 (2)

(Note this expression for r_s reduces to the ratio of r_0 to the effective Bohr radius, only in the case of quadratic bands with $g_s = 2$ and $g_v = 1$.)

Table I compares the values of r_s for the typical electron densities found in graphene sheets for N-layer graphene, with N ranging from N=1 (monolayer), to N=4 (quadlayer). The table shows that few-layer graphene offers dramatic opportunities for producing extremely strongly interacting systems at experimentally accessible densities.

The ability to access large r_s values in few-layer graphene, and thus to reach the strong electron-hole pairing regime in an experimentally accessible range of densities, motivates us to propose few-layer graphene as a system to observe electron-hole superfluidity at enhanced densities and transition temperatures.

Experimental realization of few-layer graphene is readily within the grasp of current technology since few-layer graphene sheets can be fabricated in large areas by both mechanical exfoliation^{19,20} and by chemical techniques^{21–23} from graphite with controlled stacking order. References 24–26 are examples of experimental studies on electronic and transport properties in trilayer graphene.

A schematic setup of our proposed system is depicted in Fig. 2(a). There are two parallel few-layer graphene sheets. The upper sheet of electrons and the lower sheet of holes are influenced by the top and back gates. The two sheets are separated by a thin h-BN insulating barrier to prevent tunneling between the sheets and electron-hole recombination. The separation of the graphene sheets can be as small as 1 nm (three h-BN layers) and still provide a potential barrier high

Table I | Values of the parameter r_s for few-layer graphene bilayer Density (cm⁻²) monolayer trilayer **auadlayer** 5×10^{12} 0.7 2 3 1×10^{12} 0.7 3 8 29 5 × 1011 0.7 4 17 83 1×10^{11} 86 930

enough to suppress tunneling^{12,27}. As well as the top and bottom metal gates there are separate electrical contacts to the two sheets, allowing independent control over the carrier density in each sheet.

Our aim is to provide experimental indicators for system design for observing high-T_c electron-hole superfluidity for the first time. We first evaluate the superfluid energy gap within an extended mean-field approach. Inducing electrons or holes in a few-layer graphene sheet using metallic gates imposes a perpendicular electric field. Experiments show that such a perpendicular electric field induces a band gap in the single-particle spectrum in bilayer28 and trilayer^{24,25,29,30} graphene band structures, and recent theoretical studies predict a similar effect in the energy spectrum of all few-layer graphene^{31,32}. This induced band gap makes the contributions from the graphene valence band small, and for the calculation of the superfluid gap we need to consider only contributions from the conduction band. A sketch of the energy bands for gapped bilayer, trilayer and quadlayer graphene is shown in Fig. 2(b). The highlighted region indicates the range of values for the chemical potential μ corresponding to the range of carrier densities we will consider.

Methods

We fix the electron and hole chemical potentials μ and densities n to be equal. The equations for $\Delta_{\bf k}$ and μ are

$$\Delta_{\mathbf{k}} = -\sum_{\mathbf{k}'} F_{\mathbf{k}\mathbf{k}'} V_{\mathbf{k}-\mathbf{k}'} \frac{\Delta_{\mathbf{k}'}}{2E_{\mathbf{k}'}} \quad n = g_{\mathbf{s}} g_{\mathbf{v}} \sum_{\mathbf{k}} v_{\mathbf{k}}^2. \tag{3}$$

 Δ_k is the wave-vector dependent zero temperature gap generated from pairing of electrons and holes in the conduction band. $E_k = \sqrt{\epsilon_k^2 + \Delta_k^2}$ and

 $v_k^2=(1/2)(1-\epsilon_k/E_k)$, with $\epsilon_k=E^{(N)}(k)-\mu$. The factor $F_{\mathbf{k}\mathbf{k}'}=[1+\cos[N(\phi_k-\phi_{k'})]]/2$ for N-layer graphene is associated with the square of the overlap between the single-particle states $|k\rangle$ and $|k'\rangle^{13}$.

We can take into account the finite thickness of each N-layer graphene sheet using an effective barrier thickness set equal to the physical distance perpendicular to the interface between the midpoints of the two N-layer sheets. We find this is a good approximation provided that the sheet's physical thickness is less than the thickness of the barrier separating the two N-layer sheets. This simplification is possible thanks to the strong hybridization of the electron states between the N-layers within a sheet^{29–31}. To check this, we compared the electron-hole Coulomb pairing interaction for the hybridized electrons and holes in the case of double bilayer sheets of graphene, to this approximation of two thin sheets plus effective barrier thickness. We found for physical barrier thicknesses as small as the thickness of the bilayer sheet (\approx 0.3 nm), that the resulting shift in the Coulomb pairing interaction did not exceed 5%. For the

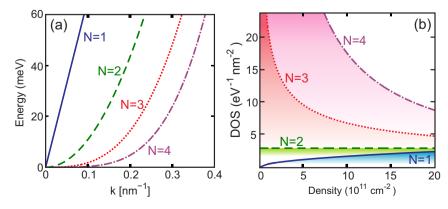


Figure 1 | (a) Lowest positive energy band in monolayer (N = 1), bilayer (N = 2), trilayer (N = 3), and quadlayer (N = 4) graphene. (b) The density of states at the Fermi energy for N = 1 to N = 4 as function of the carrier density.



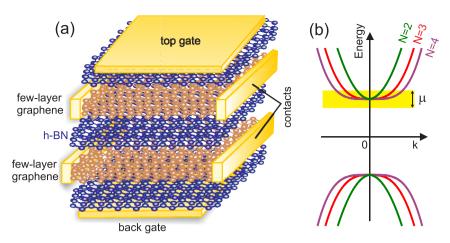


Figure 2 | (a) Schematic illustration of two few-layer graphene sheets separated by a thin barrier of h-BN layers. The electrons and holes are induced in the separately electrically contacted upper and lower graphene sheets by top and back gates. (b) Sketch of the energy bands of gapped bilayer N = 2, trilayer N = 3, and quadlayer N = 4 graphene. The yellow region around the bottom of the conduction band indicates the range of values of the chemical potential μ for our range of carrier densities.

remainder of the paper we will denote by d the effective barrier thickness. A construction similar to this is used with coupled double electron-hole quantum wells in GaAs where the finite width of the quantum wells can be treated as a form factor multiplying the electron-hole Coulomb interaction³³.

We evaluate $V_{\mathbf{k}-\mathbf{k}'}$, the static screened Coulomb interaction between electrons and holes in the two N-layer sheets $^{16,34-36}$, starting from the random phase approximation (RPA) in the normal state,

$$V_{\mathbf{q}} = \frac{\nu(q)\exp(-qd)}{1 + 2\nu(q)\Pi_0(q) + \nu(q)^2\Pi_0(q)^2[1 - \exp(-2qd)]}$$
(4)

$$\simeq \frac{\nu(q)\exp(-qd)}{1 + 2\nu(q)\Pi_0(q)} \tag{5}$$

where $v(q) = -2\pi e^2/[\kappa q]$ is the attractive bare Coulomb interaction for d=0 and $\Pi_0(q)$ the normal state particle-hole polarization bubble. The approximate expression in Eq. (5) uses the property that the most favourable conditions for pairing will occur when $k_F d \ll 1$, which is the case over the low-density range in which we work. For example, for d=2 nm and density $n=6.5\times 10^{11}$ cm², which is the highest onset density for superfluidity found in our calculations, $k_F d=0.28$.

For small momentum exchange, we can extend Eq. (5) to the broken symmetry phase at T=0 by writing the full polarization as $\Pi_0(q)=\Pi_0^{(n)}(q)+\Pi_0^{(a)}(q)$, where $\Pi_0^{(n)}(q)$ and $\Pi_0^{(a)}(q)$ are the normal and anomalous polarization bubbles in the superfluid state. At zero-temperature,

$$\begin{split} & H_0^{(n)}(q) = -2g_v \sum_{\mathbf{k}} F_{\mathbf{k}\mathbf{k} - \mathbf{q}} \frac{u_k^2 v_{\mathbf{k} - \mathbf{q}}^2 + v_k^2 u_{\mathbf{k} - \mathbf{q}}^2}{E_k + E_{\mathbf{k} - \mathbf{q}}}, \\ & H_0^{(a)}(q) = 2g_v \sum_{\mathbf{k}} F_{\mathbf{k}\mathbf{k} - \mathbf{q}} \frac{2u_k u_{\mathbf{k} - \mathbf{q}} v_k v_{\mathbf{k} - \mathbf{q}}}{E_k + E_{\mathbf{k} - \mathbf{q}}}, \end{split} \tag{6}$$

where $u_k^2 = (1 + \epsilon_k / E_k) / 2$.

 $\Pi_0^{(n)}(q)$ and $\Pi_0^{(a)}(q)$ are numerically calculated self-consistently for the few-layer graphene in the superfluid state^{13,16}. This procedure follows the approach of Ref. 13. For $k_F d \ll 1$, the full RPA-BCS screened interaction reduces to the present approximation (Eqs. (5) and (6)). Results from this approach have been tested successfully against Diffusion Quantum Monte Carlo (DQMC) results for electron-hole double layer systems ^{34,37,38}. Reference 34 found that RPA screening in the superfluid state gives satisfactory agreement with the condensate fractions 39 $c = \sum_k u_k^2 v_k^2 / \sum_k v_k^2$ calculated within DQMC over a wide parameter range, demonstrating that using self-consistent screening within the superfluid state is a good mean-field approximation.

We can neglect the intralayer correlations between electrons in the same sheet for two reasons. At high densities the electron-electron interactions are weak, while at low densities the compact pairs are weakly interacting. The satisfactory agreement for $r_s \le 3$ between the DQMC approach in Ref. 37, 38 and our present mean-field approach confirm that the intralayer correlations have little effect on the superfluid properties for $r_s \le 3$, consistent with the conclusion drawn by comparing the gaps reported in Fig. 2 of Ref. 40, which included intralayer correlations, with the gaps calculated in Ref. 41, which neglected these correlations. This comparison shows, at most, a 10–20% effect on the zero temperature gap.

In the superfluid state at low temperature, $\Pi_0(q)$ is suppressed at small momenta q because of the opening of the superfluid energy gap Δ at the Fermi surface^{42,43}. The suppression of screening permits Cooper pairs to form. However for both double

monolayer and double bilayer graphene, unless the values of the interaction parameter r_s exceeds ~ 2.3 , the screening remains too strong for superfluidity to occur at any practicable zero temperature^{13,16}. When $r_s \gtrsim 2.3$, the screening has become sufficiently suppressed by the opening of the superfluid gap that the self-consistent Cooper pairing can be strong. At finite temperature, the underlying physics leading to the superfluid transition is that for strong electron-hole pairing the fluctuations of the order parameter determine a (pseudo)gap at the critical temperature of the same order as the zero temperature superfluid gap. This large pseudogap should lead to a suppression of the screening similar to the suppression at zero temperature caused by the superfluid gap. A large pseudogap of the same order as the T=0 superfluid gap has been experimentally observed and theoretically investigated in ultracold fermionic gases in both three-dimensional⁴⁴ and two-dimensional traps^{45,46}.

Results

As a consequence of the different energy dispersions $E^{(N)}(k)$, the energy dependence of the density of states (DOS) changes dramatically with the number of layers N,

$$DOS^{(N)}(E) = \frac{2\pi}{N} \frac{t^{2(N-1)/N}}{(\hbar \nu_E)^2} E^{(2/N)-1}.$$
 (7)

Figure 1(b) shows the dependence of $DOS^{(N)}(E_F)$ at the Fermi energy on carrier density n. For monolayer graphene $DOS^{(1)}(E_F)$ depends linearly on n, for bilayer graphene $DOS^{(2)}(E_F)$ is a constant. For trilayer and quadlayer graphene, $DOS^{(N)}(E_F)$ decreases with n. $DOS^{(3)}(E_F)$ and $DOS^{(4)}(E_F)$ for small densities are much larger than $DOS^{(1)}(E_F)$ and $DOS^{(2)}(E_F)$ because of their van Hove singularities at the band bottom. At very high densities, lying far above our present range of interest, the $DOS^{(3)}(E_F)$ and $DOS^{(4)}(E_F)$ become smaller than $DOS^{(1)}(E_F)$ and $DOS^{(2)}(E_F)$.

We self-consistently solve Eqs. (3), (5) and (6) for the momentum-dependent gap $\Delta_{\mathbf{k}}$. Figure 3 shows Δ_{\max} , the maximum $\Delta_{\mathbf{k}}$ for coupled N-layer graphene with N=2, 3 and 4 for effective barrier thickness d=2 nm. For densities above an onset density n_c , if there is any superfluidity at all, the gap would be extremely small, $\Delta_{\max} \ll 1$ K. At the onset density there is a sudden discontinuous jump in Δ_{\max} to high energies of the order of the chemical potential μ . For N=3 and 4, the pairing interactions are stronger as compared to N=2, and the large-gap superfluidity is seen to persist up to significantly higher n_c .

We find that the peak in $\Delta_{\rm max}$ is located in the BEC regime. Figure 3 indicates the BEC and BEC-BCS crossover regimes which we determine using the following criterion. Condensate fractions c>0.8 correspond to the BEC regime of compact electron-hole pairs on the scale of r_0 and $0.2 < c \le 0.8$ correspond to the BEC-BCS crossover regime³⁴. $c \le 0.2$ would correspond to the weak-coupled BCS regime, but screening suppresses superfluidity at densities $n>n_c$ before the BCS regime can be reached. In the BEC regime the effect of



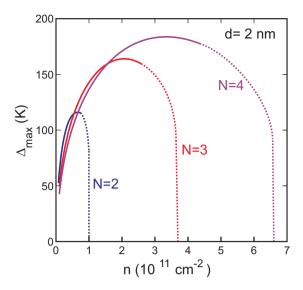


Figure 3 | Maximum of superfluid gap at zero temperature in double bilayer N=2, double trilayer N=3, and double quadlayer N=4 graphene for effective barrier thickness d=2 nm. Solid lines: BEC regime; Dotted lines: BEC-BCS crossover regime. The BCS regime is not reached.

screening is much less dramatic. We find that screening reduces the gap in the BEC regime by a factor of two or less compared with the corresponding gap calculated without screening. The reason is the compact nature of the electron-hole pairs in the BEC regime. The relation between the density dependence of the gap and the average effective Coulomb interaction and polarization function are discussed in the supplementary information (see Fig. S1).

We next determine the variation of the onset density on the number of layers N. Figure 4(a) shows the different n_c as functions of d. At a fixed d, the onset density increases with the number of layers N, and the differences become very significant as d decreases. For the double quadlayer system, n_c approaches 10^{12} cm $^{-2}$ for $d=1.5\,$ nm.

A central concern for experiments and device applications is the predicted temperature T_c for the superfluid phase transition. While in two dimensions T_c is not linearly related to the value of the zero

temperature gap Δ^{47} , nevertheless a large value of Δ through strong pairing is an essential prerequisite for a high T_c . For superfluids in two-dimensions, an upper bound on the transition temperature is the Kosterlitz-Thouless temperature T_{KT}^{47} . This is determined from

$$T_{KT} = (\pi/2)J(T_{KT}),$$
 (8)

where J(T) denotes the superfluid stiffness (the average kinetic energy of the Cooper pairs). At zero T, J(0) is proportional to the superfluid density $J(0) = \rho_s(0)/2$, since $\rho_s(0)$ controls the phase stiffness of the complex superfluid order parameter. In the mean field approach, $\rho_s(T)$ falls off only slowly with temperature when T is small compared to the zero-temperature gap so $\rho_s(T)$ is well approximated by $\rho_s(0)$ when $k_BT\ll\Delta(0)$. In an isotropic system, $\rho_s(0)$ at the mean field level is determined from 48,49

$$\rho_s(0) = g_s g_v \sum_{\mathbf{k}} \left[1 / m^*(k) \right] v_k^2,$$
(9)

where $1/m^*(k) = \partial^2 \epsilon_k / \partial k^2$ is momentum dependent. For bilayer graphene $\rho_s(0) = \left[2(\hbar v_F)^2 / t \right] n$. Note it is only for N=2 that $\rho_s(0)$ is proportional to n.

Figure 4(b) shows the maximum T_{KT} . This occurs at the onset density n_c . The maximum T_{KT} is plotted as a function of d for N=2,3, and 4. Results are shown only for cases $k_BT_{KT}<0.5\Delta_{\max}$. We see that for the same d, the enhancement of the T_{KT} with increasing N is significantly less than the corresponding enhancement of the onset density n_c (Fig. 4(a)). The reason is that in the relevant density range, the effective mass $\pm m^*(k)$ for N=3 and N=4 is larger than the effective mass m^* for N=2. This has the effect of reducing the T=0 superfluid density for N>2 as compared with the N=2 case. The larger $m^*(k)$ arise from the different band curvatures, and they partially compensate both amplification effects in the pairing gap and also the increased suppression of Coulomb screening caused by the van Hove singularities present in the DOS for N=3 and N=4. If we increase the number of layers above N=4, we expect these compensating effects will increase, making further net gains in T_c less significant.

We see in Fig. 4(b) that changing from an N=2 to an N=4 sample with the same $d \le 2$ nm, has the effect of doubling T_{KT} . Therefore in double quadlayer graphene heterostructures at currently experimentally attainable densities, $\sim 10^{12}$ cm⁻², transition

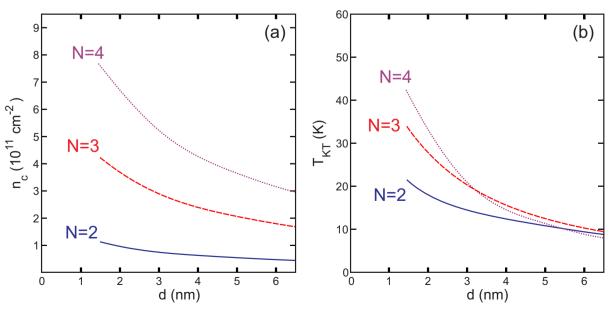


Figure 4 | (a) Maximum densities n_c for finite temperature superfluidity for the N = 2, 3, and 4 few-layer graphene systems, as function of effective barrier thickness d.



temperatures can approach temperatures of the order of 40 K. This strongly suggests that electron-hole superfluidity leading to counterflow superconductivity should be readily detectable in such samples using current technologies.

The superfluid transition should persist to higher temperatures than possible coherent states in one of the graphene sheets. This is because the superfluidity is driven by the attractive electron-hole interaction between layers which will dominate over the repulsive electron-electron interactions within a layer. Furthermore, with small effective barrier thicknesses $d \sim 2$ nm, the mean electron-hole spacing in the pairs is much smaller than r_0 for the range of densities we are considering. Thus the electron-hole pairing interaction will be much stronger than the corresponding electron-electron repulsion.

The superfluid phenomena that we have been considering are not affected by disorder for the following reasons. Reference 50 states that disorder will not destroy superfluidity for sufficiently low impurity concentrations n_i satisfying the condition $n_i \pi d^2 < k_F d$. With graphene-hBN interfaces, n_i can be $\sim 10^{10}$ cm⁻² ⁵¹⁻⁵³, so that even for wide barriers, d = 10 nm, the value of $n_i \pi d^2 \le 0.1$. At the onset densities for superfluidity we are already in the crossover regime, resulting in values of $k_F d \lesssim 1$. Thus all the samples we consider are well within the condition for negligible effects of disorder specified in Ref. 50. Furthermore even at the highest densities for which finite-temperature superfluidity occurs, we are already in the crossover regime with large superfluid gaps $\Delta_{\text{max}} > 10$ meV. Abergel et al.54,55 find that for superfluid gaps greater than a few meV, the level of fluctuations found in h-BN substrates is insufficient to destroy the electron-hole superfluidity. (It is also interesting to note that Efimkin et al. 56 quote a minimum superfluid transition temperature of 19.8 K in the weakly-interacting BCS limit in the related system of coupled electron-hole graphene monolayers even with a disorder concentration which is an order of magnitude greater than our $\sim 10^{10}$ cm⁻².) Finally, we recall that the fluctuations of the chemical potential μ associated with disorder^{54,55} are in one-to-one correspondence with density fluctuations. In the crossover regime, Ref. 41 showed that superfluid properties are insensitive to imbalances in the electron and hole densities less than 30%. This is because the sizeable smearing of the Fermi surfaces means that perfect matching of the Fermi surfaces is not necessary to stabilize superfluidity in the crossover regime.

In summary, we predict enhanced electron-hole superfluidity at temperatures up to $\sim\!40$ K in double few-layer sheets of graphene with large carrier densities as high as 10^{12} cm $^{-2}$. An important element of the physical mechanism is that increasing the number of graphene layers in each sheet has the effect of greatly enhancing the density of states (Fig. 1(b)). This enhancement projects the sheets into the strongly interacting regime, leading to strong electron-hole pairing at large accessible densities. Over the full range of system parameters considered, we established that disorder effects will play a minor role on superfluid properties. The experimental parameters of our proposed device have all been attained in related graphene systems 29,30,57 .

- Lozovik, Yu. E. & Yudson, V. I. Feasibility of superfluidity of paired spacially separated electrons and holes: a new superconductivity mechanism. *Pis'ma Zh. Eksp. Teor. Fiz.* 22, 556–559 (1975) [JETP Lett. 22, 274 (1975)].
- Min, H., Bistritzer, R., Su, J. & MacDonald, A. H. Room-temperature superfluidity in graphene bilayers. *Phys. Rev. B* 78, 121401(R) (2008).
- Vignale, G. & MacDonald, A. H. Drag in Paired Electron-Hole Layers. Phys. Rev. Lett. 76, 2786 (1996).
- Croxall, A. F. et al. Anomalous Coulomb Drag in Electron-Hole Bilayers. Phys. Rev. Lett. 101, 246801 (2008).
- Seamons, J. A., Morath, C. P., Reno, J. L. & Lilly, M. P. Coulomb Drag in the Exciton Regime in Electron-Hole Bilayers. *Phys. Rev. Lett.* 102, 026804 (2009).
- 6. Gamucci, A. *et al.* Electron-hole pairing in graphene-GaAs heterostructures. http://arxiv.org/abs/1401.0902 (2004) Date of access: 28/11/2014.
- Novoselov, K. S. et al. Electric Field Effect in Atomically Thin Carbon Films. Science 306, 666 (2004).
- 8. Castro Neto, A. H., Guinea, F., Peres, N. M. R., Novoselov, K. S. & Geim, A. The electronic properties of graphene. *Rev. Mod. Phys.* **81**, 109 (2009).

- 9. Beenakker, C. W. J. Colloquium: Andreev reflection and Klein tunneling in graphene. *Rev. Mod. Phys.* **80**, 1337 (2008).
- Zhang, C.-H. & Joglekar Yogesh, N. Excitonic condensation of massless fermions in graphene bilayers. *Phys. Rev. B* 77, 233405 (2008).
- Zhang, J. & Rossi, E. Chiral Superfluid States in Hybrid Graphene Heterostructures. *Phys. Rev. Lett.* 111, 086804 (2013).
- 12. Gorbachev, R. V. et al. Strong Coulomb drag and broken symmetry in double-layer graphene. *Nature Phys.* **8**, 896 (2012).
- Lozovik, Yu. E., Ogarkov, S. L. & Sokolik, A. A. Condensation of electron-hole pairs in a two-layer graphene system: Correlation effects. *Phys. Rev. B* 86, 045429 (2012).
- Das Sarma, S., Adam, Sh., Hwang, E. H. & Rossi, E. Electronic transport in twodimensional graphene. Rev. Mod. Phys. 83, 407 (2011).
- Dean, C. R. et al. Boron nitride substrates for high-quality graphene electronics. Nature Nanotechnol. 5, 722 (2010).
- Perali, A., Neilson, D. & Hamilton, A. R. High-Temperature Superfluidity in Double-Bilayer Graphene. *Phys. Rev. Lett.* 110, 146803 (2013).
- Min, H. & MacDonald, A. H. Chiral decomposition in the electronic structure of graphene multilayers. *Phys. Rev. B* 77, 155416 (2008).
- Katsnelson, M. I. Graphene: Carbon in two dimensions. Cambridge University Press, New York (2012).
- Ferrari, A. C. et al. Raman Spectrum of Graphene and Graphene Layers. Phys. Rev. Lett. 97, 187401 (2006).
- Zhang, Y., Small, J. P., Pontius, W. V. & Kim, Ph. Fabrication and electric-field-dependent transport measurements of mesoscopic graphite devices. *Appl. Phys. Lett.* 86, 073104 (2005).
- Berger, C. et al. Ultrathin Epitaxial Graphite: 2D Electron Gas Properties and a Route toward Graphene-based Nanoelectronics. J. Phys. Chem. B 108, 19912 (2004).
- 22. Shih, C. J. et al. Bi- and trilayer graphene solutions. Nat Nanotechnol. 6, 439–445 (2011).
- Mahanandia, P., Simon, F., Heinrich, G. & Nanda, K. K. An electrochemical method for the synthesis of few layer graphene sheets for high temperature applications. *Chem. Commun.* 50, 4613 (2014).
- 24. Craciun, M. F. *et al.* Trilayer graphene is a semimetal with a gate-tunable band overlap. *Nature Nanotech.* **4**, 383 (2009).
- 25. Bao, W. et al. Stacking-dependent band gap and quantum transport in trilayer graphene. Nature Phys. 7, 948 (2011).
- Mak, K. F., Shan, J. & Heinz, T. F. Electronic Structure of Few-Layer Graphene: Experimental Demonstration of Strong Dependence on Stacking Sequence. *Phys. Rev. Lett.* 104, 176404 (2010).
- Geim, A. K. & Grigorieva, I. V. Van der Waals heterostructures. *Nature* 499, 419 (2013).
- Zhang, Y. et al. Direct observation of a widely tunable bandgap in bilayer graphene. Nature 459, 820 (2009).
- Lui, Ch. H. et al. Observation of an electrically tunable band gap in trilayer graphene. Nature Phys. 7, 944 (2011).
- Zou, K., Zhang, F., Clapp, C., MacDonald, A. H. & Zhu, J. Transport Studies of Dual-Gated ABC and ABA Trilayer Graphene: Band Gap Opening and Band Structure Tuning in Very Large Perpendicular Electric Fields. *Nano Lett.* 13, 369 (2013)
- Avetisyan, A. A., Partoens, B. & Peeters, F. M. Stacking order dependent electric field tuning of the band gap in graphene multilayers. *Phys. Rev. B* 81, 115432 (2010).
- Tang, K. et al. Electric-Field-Induced Energy Gap in Few-Layer Graphene. J. Phys. Chem. C 115, 9458 (2011).
- Tan, I.-H., Snider, G. L., Chang, L. D. & Hu, E. L. A self-consistent solution of Schrödinger-Poisson equations using a nonuniform mesh. J. Appl. Phys. 68, 4071 (1990).
- 34. Neilson, D., Perali, A. & Hamilton, A. R. Excitonic superfluidity and screening in electron-hole bilayer systems. *Phys. Rev. B* **89**, 060502(R) (2014).
- Kharitonov Maxim, Yu. & Efetov Konstantin, B. Electron screening and excitonic condensation in double-layer graphene systems. Phys. Rev. B 78, 241401 (2008).
- Sodemann, I., Pesin, D. A. & MacDonald, A. H. Interaction-enhanced coherence between two-dimensional Dirac layers. *Phys. Rev. B* 85, 195136 (2012).
- Maezono, R., Ríos, P. L., Ogawa, T. & Needs, R. J. Excitons and biexcitons in symmetric electron-hole bilayers. *Phys. Rev. Lett.* 110, 216407 (2013).
- De Palo, S., Rapisarda, F. & Senatore, G. Excitonic Condensation in a Symmetric Electron-Hole Bilayer. *Phys. Rev. Lett.* 88, 206401 (2002).
- Salasnich, L., Manini, N. & Parola, A. Condensate fraction of a Fermi gas in the BCS-BEC crossover. *Phys. Rev. A* 72, 023621 (2005).
- Zhu, X., Littlewood, P. B., Hybertsen, M. S. & Rice, T. M. Exciton Condensate in Semiconductor Quantum Well Structures. *Phys. Rev. Lett.* 74, 1633 (1995).
- Pieri, P., Neilson, D. & Strinati, G. C. Effects of density imbalance on the BCS-BEC crossover in semiconductor electron-hole bilayers. *Phys. Rev. B* 75, 113301 (2007).
- Gortel, Z. & Świerkowski, L. Superfluid ground state in electron-hole double layer systems. Surf. Sci. 361, 146 (1996).
- Bistritzer, R., Min, H., Su, J.-J. & MacDonald, A. H. Comment on "Electron screening and excitonic condensation in double-layer graphene systems." http:// arxiv.org/abs/0810.0331v1 (2008) Date of access: 28/11/2014.
- Gaebler, J. P. et al. Observation of pseudogap behaviour in a strongly interacting Fermi gas. Nat. Phys. 6, 569 (2010).



- 45. Feld, M., Fröhlich, B., Vogt, E., Koschorreck, M. & Köhl, M. Observation of a pairing pseudogap in a two-dimensional Fermi gas. Nature (London) 480, 75 (2011).
- 46. Marsiglio, F., Pieri, P., Perali, A., Palestini, F. & Strinati, G. C. Pairing effects in the normal phase of a two-dimensional Fermi gas. http://arxiv.org/abs/1406.7761v1 (2014) Date of access: 28/11/2014.
- $47.\ Kosterlitz,$ J. M. & Thouless, D. J. Ordering, metastability and phase transitions in two-dimensional systems. J. Phys. C: Solid State Phys. 6, 1181 (1973).
- 48. Benfatto, L., Capone, M., Caprara, S., Castellani, C. & Di Castro, C. Multiple gaps and superfluid density from interband pairing in a four-band model of the iron oxypnictides. Phys. Rev. B 78, 140502(R) (2008).
- 49. Benfatto, L. & Sharapov, S. G. Optical-conductivity sum rule in cuprates and unconventional charge density waves: a short review. Low Temp. Physics 32, 533
- 50. Bistritzer, R. & MacDonald, A. H. Influence of Disorder on Electron-Hole Pair Condensation in Graphene Bilayers. Phys. Rev. Lett. 101, 256406 (2008).
- 51. Martin, J. et al. Observation of electron-hole puddles in graphene using a scanning single-electron transistor. Nat. Phys. 4, 144 (2008).
- 52. Decker, R. et al. Local Electronic Properties of Graphene on a BN Substrate via Scanning Tunneling Microscopy. Nano Letters 11, 2291 (2011).
- 53. Xue, J. et al. Scanning tunnelling microscopy and spectroscopy of ultra-flat graphene on hexagonal boron nitride. Nat. Mater. 10, 282 (2011).
- 54. Abergel, D. S. L., Sensarma, R. & Das Sarma, S. Density fluctuation effects on the exciton condensate in double-layer graphene. Phys. Rev. B 86, 161412(R) (2012).
- 55. Abergel, D. S. L., Rodriguez-Vega, M., Rossi, E. & Das Sarma, S. Interlayer excitonic superfluidity in graphene. Phys. Rev. B 88, 235402 (2013).
- 56. Efimkin, D. K., Kulbachinskii, V. A. & Lozovik, Yu. E. Influence of Disorder on Electron-Hole Pairing in Graphene Bilayer. JETP Lett. 93, 238 (2011).

57. Lee, K. et al. Chemical potential and quantum Hall ferromagnetism in bilayer graphene. Science 345, 58 (2014).

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Author contributions

D.N. and F.P. conceived the idea and supervised the project. D.N. and A.P. designed the calculation, and A.P. and M.Z. carried out the calculation. All authors contributed to the analysis and interpretation of the results. D.N., A.P. and M.Z. wrote the paper.

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